

GaAs MESFET Transistor

March 2008 - Rev 15-Mar-08

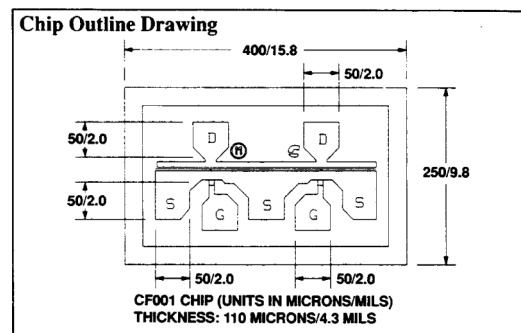
CF001-01

Features

- ✕ High Gain: Usable to 44 GHz
- ✕ P1dB Power: 21 dBm
- ✕ Wfer Qualification Procedure
- ✕ Customer Wafer Selection Available

General Description

Mimix CF001-01 GaAs-based transistor is a 300 um gate width, sub-half-micron gate length GaAs device with Silicon Nitride passivation. The CF001-01 provides high gain up to 26 GHz. It is suitable for general purpose and driver amplifier applications with up to +21 dBm power from a single FET. This device can also be used in oscillator applications. The CF001-01 is available in chip form and is suitable for airborne, shipboard and ground-based equipment. The devices are 100% DC tested and every wafer is qualified based on sample RF and reliability testing. Screening includes MIL-STD-750 Class B, Class S and commercial screening. These devices are also available in packaged form. Please consult the CFB0101-B, CFA0101-A datasheets or contact the factory for further information.



Absolute Maximum Ratings

Parameter	Symbol	Rating
Drain-Source Voltage	V_{DS}	8V
Gate-Source Voltage	V_{GS}	-5V
Drain Current	I_{DS}	I_{DSS}
Continuous Dissipation	P_T	800 mW
Channel Temperature	T_{CH}	175°C
Storage Temperature	T_{STG}	-65°C to +175°C

Specifications ($T_A = 25^\circ\text{C}$)

CF001-01

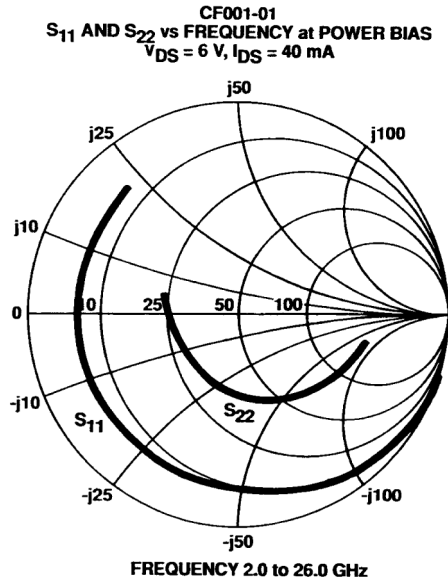
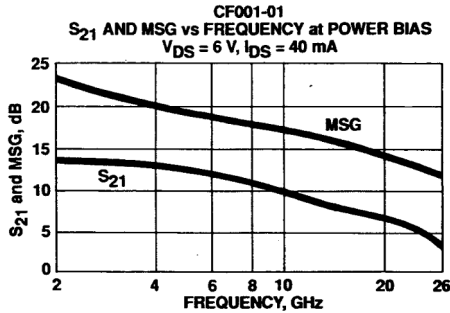
Active Layer				Ion Implanted		
Symbol	Parameters and Conditions	Frequency (GHz)	Units	Min	Typ	Max
NF_{opt}	Optimum Noise Figure $V_{DS} = 3.0\text{ V}, I_{DS} = 15\text{ mA}$	12.0	dB		1.6	2.4
Ga	Gain at NF_{opt} $V_{DS} = 3.0\text{ V}, I_{DS} = 15\text{ mA}$	12.0	dB	7.5	8.5	
$ S_{21} ^2$	50 Ohm Insertion Gain $V_{DS} = 6.0\text{ V}, I_{DS} = 40\text{ mA}$	2.0	dB		13.0	
		10.0	dB		9.5	
		18.0	dB		6.0	
P_{1dB}	Power Output @ 1 dB GC $V_{DS} = 6.0\text{ V}, I_{DS} = 40\text{ mA}$	12.0	dBm		21.0	
g_m	Transconductance $V_{DS} = 3.0\text{ V}, V_{GS} = 0\text{ V}$		mS		60	
I_{DSS}	Drain Current $V_{DS} = 3.0\text{ V}, V_{GS} = 0\text{ V}$		mA	40	60	120
V_p	Pinchoff Voltage $V_{DS} = 3.0\text{ V}, I_{DS} = 1\text{ mA}$		Volts	-0.7	-1.3	-2.5
BV_{GD}	Breakdown Voltage, Gate-Drain $I_{GD} = 100\text{ }\mu\text{A}$		Volts	-5.5	-8.0	
R_{th}	Thermal Resistance		°C/W		150	

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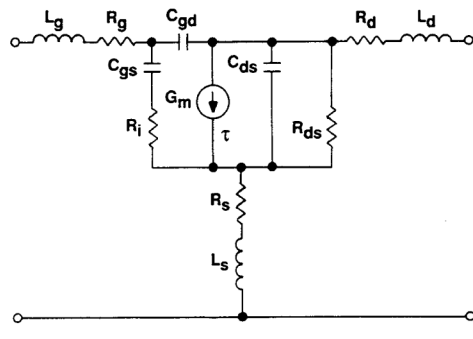
Typical Scattering Parameters, Common Source (S-Parameters Include Bonding Wire Parasitics)

CF001-01 at Power Bias V_{DS} = 6 V, I_{DS} = 40 mA

Frequency (GHz)	S ₁₁		S ₂₁		S ₁₂		S ₂₂		K	MSG (dB)		
	(Mag)	(Ang)	(dB)	(Mag)	(Ang)	(dB)	(Mag)	(Ang)				
2.0	0.98	-24	13.2	4.56	156	-33.2	0.02	73	0.53	-10	0.27	23.2
4.0	0.93	-51	12.7	4.31	136	-27.7	0.04	62	0.50	-25	0.34	20.2
6.0	0.88	-72	11.7	3.83	118	-25.3	0.05	51	0.48	-35	0.46	18.5
8.0	0.84	-98	10.8	3.47	100	-23.8	0.06	38	0.43	-51	0.55	17.3
10.0	0.79	-122	9.5	2.99	82	-24.1	0.06	23	0.38	-68	0.83	16.8
12.0	0.79	-140	8.4	2.64	67	-23.3	0.07	18	0.38	-83	0.79	15.9
14.0	0.78	-154	7.6	2.41	55	-23.2	0.07	10	0.39	-93	0.86	15.4
16.0	0.78	-166	7.1	2.27	44	-22.5	0.07	5	0.36	-101	0.90	14.8
18.0	0.77	-178	6.7	2.16	30	-21.8	0.08	-2	0.32	-113	0.93	14.2
20.0	0.76	-159	6.2	2.04	15	-21.0	0.09	-13	0.27	-131	0.95	13.6
22.0	0.79	141	5.2	1.82	-2	-20.8	0.09	-20	0.27	-163	0.91	13.0
24.0	0.78	132	3.7	1.52	-13	-20.9	0.09	-21	0.30	176	1.12	12.3
26.0	0.81	129	2.3	1.31	-21	-20.5	0.09	-19	0.39	168	0.91	11.4

Device Model

Parameters	CF001-01	CF001-03	Units
	V _{DS} = 6V, I _{DS} = 40mA	V _{DS} = 3V, I _{DS} = 15mA	
L _g	0.19	0.26	nH
R _g	1.0	1.0	Ω
C _{gs}	0.32	0.24	pF
R _i	1.9	1.6	Ω
C _{gd}	0.023	0.029	pF
G _m	66	66	mS
τ	2.7	2.1	ps
C _{ds}	0.12	0.10	pF
R _{ds}	161	171	Ω
R _d	1.3	1.3	Ω
L _d	0.21	0.23	nH
R _s	1.1	1.6	Ω
L _s	0.04	0.04	nH



Wafer Qualification Procedure

- 100% DC Test
100% Visual Insp.
 - Sample Chip Performance Test
NF, Power, S-Parameters, IPS, Power Blast
 - Sample Circuit Performance Tests
6-18 GHz Module
NF, Power, Gain, VSWR
 - Reliability Assessment
Power Blast & Burn-In
- 80% of tested samples must meet specifications for wafer acceptance.

Mimix Broadband, Inc., 10795 Rockley Rd., Houston, Texas 77099
Tel: 281.988.4600 Fax: 281.988.4615 mimixbroadband.com

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Handling and Assembly Information

CAUTION! - Mimix Broadband MMIC Products contain gallium arsenide (GaAs) which can be hazardous to the human body and the environment. For safety, observe the following procedures:

- *Do not ingest.*
- *Do not alter the form of this product into a gas, powder, or liquid through burning, crushing, or chemical processing as these by-products are dangerous to the human body if inhaled, ingested, or swallowed.*
- *Observe government laws and company regulations when discarding this product. This product must be discarded in accordance with methods specified by applicable hazardous waste procedures.*

Life Support Policy - Mimix Broadband's products are not authorized for use as critical components in life support devices or systems without the express written approval of the President and General Counsel of Mimix Broadband. As used herein: (1) Life support devices or systems are devices or systems which, (a) are intended for surgical implant into the body, or (b) support or sustain life, and whose failure to perform when properly used in accordance with instructions for use provided in the labeling, can be reasonably expected to result in a significant injury to the user. (2) A critical component is any component of a life support device or system whose failure to perform can be reasonably expected to cause the failure of the life support device or system, or to affect its safety or effectiveness.

ESD - Gallium Arsenide (GaAs) devices are susceptible to electrostatic and mechanical damage. Die are supplied in antistatic containers, which should be opened in cleanroom conditions at an appropriately grounded antistatic workstation. Devices need careful handling using correctly designed collets, vacuum pickups or, with care, sharp tweezers.

Die Attach: Conductive epoxy or preform die attach is recommended. For preform die attach: Preform: AuSn (80% Au, 20% Sn); Stage Temperature: 290 °C, +/-5 °C; Handling Tool: Tweezers; Time: 1 min or less.

Wire Bonding: Wire Size: 0.7 to 1.0 mil in diameter (pre-stressed); Thermocompression bonding is preferred over thermosonic bonding. For thermocompression bonding: Stage Temperature: 250 °C ; Bond Tip Temperature: 150 °C; Bonding Tip Pressure: 18 to 40 gms depending on size of wire.

RoHS Compliant Parts - All Mimix products are RoHS compliant unless otherwise specified.

Ordering Information

Part Number for Ordering

CF001-01-000X

Description

Where "X" is RoHS compliant die packed in "V" - vacuum release gel packs or "W" - waffle trays



Proper ESD procedures should be followed when handling this device.